

(Use several sheets if necessary)

Application Number

10/726, 104

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2822

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	PLUNG DATE & APPROPRIATE
KBT	5380546	11/10/95	Krishnan et al.	427	126.1	6/9/93
2004	5451551	9/19/95	Krishnan et al.	437	241	8/15/94
	6251786	6/26/01	Zhou et al.	438	692	9/7/99
	6258713	7/10/01	Yu et al.	438	634	12/3/99
	6274499	8/14/01	Gupta et al.	438	692	11/19/99
	6114246	9/5/00	Weling	438	691	1/7/99
	6103625	8/15/00	Marcynk et al.	438	691	12/31/97
Y	6083835	7/4/00	Shue et al.	438	687	7/24/98

[illegible]

KBD	-	The article entitled "Finding the Ultimate Copper Barrier and Seed" by Peters, Semiconductor International, July 2001, p. 23.

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.